## **Tuning the Energy Level Offset between Donor and Acceptor with Ferroelectric Dipole Layers for Increased Efficiency in Bilayer Organic Photovoltaic Cells**

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## **Research motivation**



> Organic photovoltaic (OPV) technology is one of the most attractive candidates for solving future energy shortage problem due to its advantage of light weight, flexibility, low cost and large scale production.



Typical device structure

**Device working principle** 

V<sub>oc</sub> / Bandgap of polymer

> Power conversion efficiency (PCE) of OPV devices already exceeds 10%, further increasing the PCE to over 15% is needed for OPV to compete with silicon solar cells and other thin film photovoltaic technologies.  $\geq$  In polymer solar cells with PCE over 6%, none of them has open circuit voltage (V<sub>oc</sub>) reaching half of the optical bandgap of the semiconducting polymers, caused by the too large lowest unoccupied molecular orbital (LUMO) offsets between the donors and the acceptors.



Voltage /V Under dark

## Conclusions

> We demonstrated a method to increase the V<sub>oc</sub> of bilayer OPV devices by tuning the energy level offset of the donor and the acceptor with tunable ferroelectric P(VDF-TrFE) dipole layers.

> Both J<sub>sc</sub> and FF also increased due to the reduced recombination loss of charge transfer excitons. Thus, a double efficiency was achieved for P3HT and PCBM based bilayer OPV devices.

 $\geq$  We expect that a further increase of V<sub>oc</sub> can be achieved by improving the coverage of the P(VDF-TrFE) dipole layer on P3HT.  $\geq$  The V<sub>oc</sub> can be potentially improved to above 1.0 V without compromising other photovoltaic parameters such as J<sub>sc</sub> and FF.

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 $\geq$  The Voc of OPV devices is determined by the difference of LUMO (or conduction band) of the acceptor material and HOMO (or valence band) of the donor material. A small LUMO offset between the donor and the acceptor is preferred for a high Voc.

> A tunable dipole layer, consisting of an ultrathin ferroelectric polymer film, was inserted between the donor and the acceptor semiconductor layers, which shifts the relative energy levels of the donor and the acceptor. Therefore, the Voc could be increased by tuning the LUMO offset between the donor and the acceptor without changing their chemical structures. It is thus a general method to increase the efficiency of OPV devices consisting of any active materials.









Local piezoelectric response of the P(VDF-TrFE) grains imbedded under thin PCBM layer (20 nm)

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 $\succ$  Thus, the PCE was more than doubled from 1.5% to 3.3%.

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> As shown in Figure a-b, only approximately 20% of the P3HT surface was covered by the ferroelectric P(VDF-TrFE) nanoislands. It could explain why the obtained  $V_{oc}$  is far less than the maximum attainable V<sub>oc</sub> of 1.5 V since most of the P3HT polymers directly contact with PCBM molecules.

 $\succ$  Figure c-f showed that the inserted P(VDF-TrFE) layer was in the ferroelectric state which could be switched between two states by applying opposite



> In this work, a polyvinylidene fluoride (70%)-trifluoroethylene (30%) copolymer, P(VDF-TrFE), was used as the tunable dipole layer, which was coated by Langmuir-Blodgett (LB) deposition technique. > The P(VDF-TrFE) layer was sandwiched between P3HT and PCBM bilayers which can precisely grow the ferroelectric layer thickness by monolayer (ML) and generates P(VDF-TrFE) with excellent crystallinity.

> According to above equation, a thickness as thin as 0.6 nm P(VDF-TrFE), about one monomolecular layer, is needed to induce an energy level shift of 0.8 eV.  $\geq$  The P3HT/PCBM system, however, has a V<sub>oc</sub> output of only about 0.6 V, which is significantly lower than the optical bandgap (~2.0 eV) of P3HT. This discrepancy is caused by a very large LUMO offset close to 1.0 eV. > The maximum attainable V<sub>oc</sub> of 1.5 V which assumes LUMO offset 0.2 V loss for the efficient charge transfer and a  $V_{oc}$  loss of 0.3 V due to the non-ideal diode in P3HT/PCBM OPV devices.

## Electrostatic force microscopy measurement



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## **Device fabrication and maximum attainable V**<sub>oc</sub>

**Real device** 

$$d = \frac{\varepsilon_0 \varepsilon_{FE} E}{\sigma_P q}$$



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As shown in the figure a-d, the average surface potential difference is 0.1 V, which is consistent with tuned V<sub>oc</sub>.

 $\succ$  The fluctuation of surface potential is consistent the nonuniform distribution of the with ferroelectric P(VDF-TrFE) nanoislands on P3HT layer. This result indicates a large potential to further increase the energy tuning capability by the ferroelectric dipoles with increased coverage of the dipole layer.